



Alexandria University
Faculty of Engineering
Division of Communications & Electronics

EE 4E4 VLSI Modeling and Design
Sheet 3

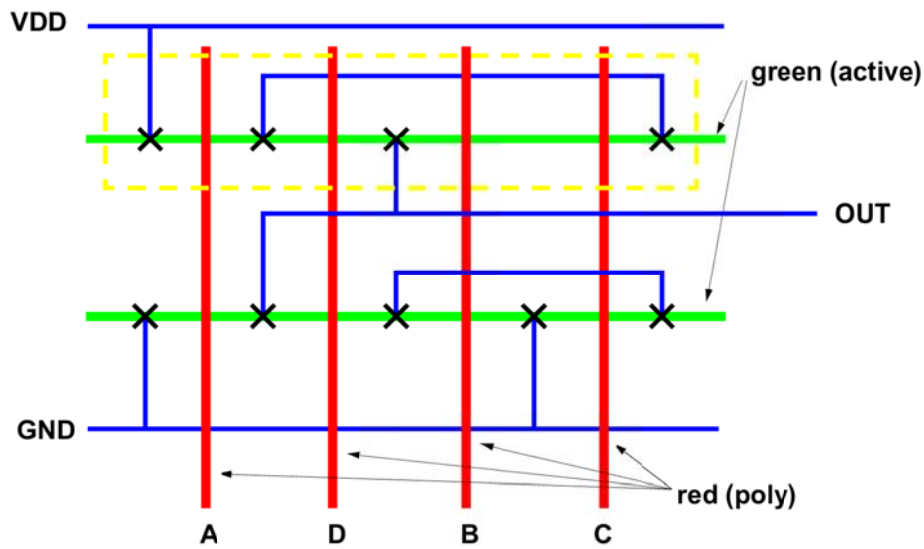
1. Draw the schematic for the CMOS circuit that implements the function F described by the truth table below. Use the least possible number of transistors. Explain your procedure and show the reduced function equation used to design the schematic.

<i>Inputs</i>			<i>Output</i>
X	Y	Z	F
0	0	0	1
0	0	1	1
0	1	0	0
0	1	1	0
1	0	0	1
1	0	1	1
1	1	0	0
1	1	1	1

2. Sketch a color-coded stick diagram for the circuit that implements the function $f = \overline{a + b.c + d}$. Organize the layout so that the transistors can be implemented on a continuous strip of active (i.e., do not break the active).
3. Design a CMOS circuit to implement the following function $f = \overline{x.(y.z + z.w)}$
 - a. Construct the schematic for the circuit using the minimum number of transistors.
 - b. Sketch the layout for this circuit using a stick diagram using colored pencils/pens/crayons. Show the Euler Path used for

your stick diagram on your schematic. The stick diagram should include the active (green), poly (red), metal (blue), and contact (black X) layers and should be implemented between a power (VDD) and ground rail.

4. Identify the fabrication process required to produce the following transistor/circuit features. Choose from the following options: photolithography, diffusion, ion implantation, dielectric deposition, thermal oxidation, chemical etching, or reactive ion etching.
 - a. Formation of a native oxide layer at high temperatures
 - b. Reproduction of a layout pattern onto a photoresist layer on the surface of a chip
 - c. Impurity doping with a maximum concentration at the surface of the wafer
 - d. Removal of material with an anisotropic profile
 - e. Creation of an insulator layer between metal layers
5.
 - a. Draw the schematic for the circuit that implements $f = \frac{x}{y + z + w}$
 - b. Using an inverter with $\beta_n = \beta_p$, as a sizing reference, determine the size of each transistor in this circuit that will equalize the nMOS and pMOS resistances. That is, specify size of each transistor (in terms of β) relative to β_n or β_p .
 - c. Draw the layout of the CMOS realization of the function f for the specified transistor sizes.
6. Consider the following stick diagram. Draw the transistor-level schematic. What logic equation does the circuit implement?



7. Draw a side-view diagram for each of the cuts X and Y through the layout below. Be sure to label each of the strata. What is the logic equation represented by the layout.

-  poly
-  metal
-  active
-  well
-  via

